



Formulation

Acrylic DTM with HALOX® 580

Grind	% Wt./Wt.	Class	Supplier
De-Ionized Water	5.86		
Tamol 165A	0.93	Dispersant	Dow Chemical
AMP-95	0.02	Amine	Advancion Chemical
BYK-024	0.10	Defoamer	BYK
Ti-Pure R-706	17.24	Pigment	Dupont
HUBERCARB G3	7.18	Pigment	Huber
<i>High speed disperse to 5+ NS Hegman grind.</i>			
LETDOWN			
Add grind portion			
De-Ionized Water	0.96		
ALBERDINGK AC 2403	56.8	Resin	Alberdingk Boley
TEGO AIREX 902 W	0.19	Defoamer	Evonik
BYK 333	0.18	Surface Additive	BYK
HALOX 580	1.9	Liquid Corrosion Inhibitor	ICL
AMP-95	0.15	Amine	Advancion Chemical
De-Ionized Water	1.9		
Add slowly while mixing			
Texanol	1.51	Co-solvent	Eastman
Optifilm Enhancer 400	1.92		Eastman
HALOX FLASH-X 150	0.5	Flash Rust Inhibitor	ICL
Premix the next 3 ingredients before adding			
De-Ionized Water	1.9		
Dowanol DPM	0.49	Co-solvent	Dow Chemical
Acrysol RM-8W	0.27	Rheology Modifier	Dow Chemical
TOTAL	100		
Formula Constants		Formula Properties	
% Solids/wt	53.80	VOC g/l	57.00
% Solids/vol	45.60	Density lbs/gal	10.44
PVC	20.00		

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